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## Claims

- 1. An assembly comprising a plurality of mask containers, each for holding one or more lithography masks, wherein 5 each one of the containers has an engaging apparatus adapted to engage with the corresponding engaging apparatus on another one of the containers, such that two or more containers can be stacked together in a fixed relationship to one another, and wherein each 10 mask container has an electronic tracking device, the tracking device having a receiver unit for receiving lithography data, a memory for storing the lithography data, a processor unit for reading or writing the lithography data to or from the memory, and a 15 transmitter unit for transmitting the lithography data read from the memory.
- 2. The assembly as claimed in claim 1, wherein the
  engaging apparatus comprises a latch mounted on one
  face of the container, and a catch mounted on an
  opposite face of the container, such that two or more
  mask containers may be engaged by engaging the latch of
  one mask with the catch of another mask.

3. The assembly as claimed in claim 1, wherein each container has electrical contacts positioned such that contacts on two neighbouring containers in a stack form an electrical connection when the two containers are correctly positioned relative to each other. 4. The assembly as claimed in claim 1, wherein the receiver unit and the transmitter unit respectively receive and transmit radio frequency radiation.

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- 5. The assembly as claimed in claim 1, wherein the receiver unit and the transmitter unit respectively receive and transmit infra-red radiation.
- 10 6. The assembly as claimed in claim 1, wherein the memory is an EEPROM.
  - 7. The assembly as claimed in claim 1, wherein the memory is an SRAM.

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8. The assembly as claimed in claim 1, wherein the tracking devices of the mask containers in a stack are adapted to communicate lithography data with each other.

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9. The assembly as claimed in claim 8, wherein the tracking devices in each container are programmed to identify the other containers in the stack and select between themselves one tracking device to transmit lithography data representative of all the containers in the stack.

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- 10. A manufacturing system for manufacturing semiconductor devices comprising:
  - a plurality of mask containers, each for holding one or more lithography masks, each one of the containers having a locking apparatus adapted to engage with the locking apparatus on another one of the containers, such that two or more containers can be carried together in a fixed relationship to one another;
- 10 a plurality of lithography bays;
  - a transport rail system for carrying the containers between different lithography bays;
  - wherein each lithography bay has a transmitter unit and a receiver unit for respectively transmitting and receiving lithography data, and each mask container has an electronic tracking device having a receiver unit for receiving lithography data from a lithography bay, a memory for storing the lithography data, a processor unit for reading or writing the lithography data to or from the memory, and a transmitter unit for transmitting the

lithography data read from the memory to the same

lithography bay or another lithography bay.

25 11. The manufacturing system as claimed in claim 10, wherein a handling apparatus is provided for automatically loading or unloading mask containers onto or from the rail system.

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- 12. The manufacturing system as claimed in claim 11, wherein there is provided a handling apparatus for bringing mask containers into stacked engagement with one another and for releasing a container from a stack or automatically removing a mask from a container.
- 13. The manufacturing system as claimed in claim 11, wherein there is provided a central computer with an input and output port for exchanging lithography data with the mask containers and the lithography bays.
- 14. The manufacturing system as claimed in claim 13, wherein the rail system is provided with a traction apparatus for moving the mask containers and wherein the traction apparatus is controlled by the central computer.

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- 15. A manufacturing system for manufacturing semiconductor devices comprising:
  - a plurality of mask containers, each for holding one or more lithography masks;
- 5 a plurality of lithography bays;
  - a transport rail system for carrying the containers between different lithography bays, the transport rail system having a carrier and the mask containers each having an engaging apparatus for engaging with the carrier such that the mask containers can be carried by the rail system;
  - wherein each lithography bay has a transmitter unit and a receiver unit for respectively transmitting and receiving lithography data, and each mask container has an electronic tracking device having a receiver unit for receiving lithography data from a lithography bay, a memory for storing the lithography data, a processor unit for reading or writing the lithography data to or from the memory, and a transmitter unit for transmitting the lithography data read from the memory to the same lithography bay or another lithography bay.
- 16. The manufacturing system of claim 15, wherein said rail system carries the mask containers in a stack.
  - 17. The manufacturing system of claim 15, wherein said rail system carries the mask containers in a frame with slots.

18. An assembly comprising a plurality of mask containers, each for holding one or more lithography masks, wherein each one of the containers has an engaging apparatus adapted to engage with an engaging apparatus on another one of the containers, such that two or more containers can be stacked together in a fixed relationship to one another, and wherein each mask container has an electronic tracking device, the tracking device having a receiver unit for receiving first lithography data, a memory for temporarily storing the first lithography data, a processor unit for processing the first lithography data and for providing second lithography data, and a transmitter unit for transmitting the second lithography data.

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19.	A method of operating a semiconductor device
	manufacturing system, the manufacturing system
	comprising a plurality of mask containers each
	containing a single mask and each container having a
	tracking device for transmitting and receiving data
	corresponding to the mask within the container, the
	method comprising the following steps:
	receiving lithography data from a plurality of mask
	containers, selecting two or more containers on th

basis of the received lithography data; operating a first automatic handling device so as to group together the selected containers in the form of a stack and to place the stack on a rail system

tool apparatus;

operating the rail system so as to transport the stack to the lithography bay;

connecting to a lithography bay having an exposure

further operating the exposure tool apparatus to receive lithography data from at least one of the mask containers in the stack; and,

- operating the lithography tool according to the data received from a mask container in the stack; wherein operating the lithography tool comprises at least one step out of the group of the following steps:
- removing a mask from a container;
  - inserting a mask into a container;
  - removing a mask, returning the mask to a container and subsequently removing another mask from a different container
- unstacking the containers in a stack

- reassembling a stack
- adding data to a mask in electronic form;
- reading data from a mask;
- exposing a semiconductor wafer or any other workproduct by sending electromagnetic radiation through a mask;
  - storing a mask;
  - manufacturing a mask;
  - maintaining a mask;
  - monitoring the transmission properties of a mask;
  - damaging a mask, disposing of a mask, recycling a mask, or any other action that removes a mask from the factory;
  - testing and measuring the properties of a mask, either directly, or indirectly;
  - assigning an identifier for a mask;
  - assigning an identifier for a plurality of masks; and
- transferring information that relates to a mask 20 from a first electronic device in a first container to a further electronic device in a further container.

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